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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: Wu et al. § Attorney Docket No. TSMC2002-1168 /  
§ 24061.27  
Serial No.: 10/687,314 § Customer No. 42717  
Filed: October 16, 2003 § Group Art Unit: 2826  
For: ELECTROSTATIC DISCHARGE § Examiner: Wilson, Scott R.  
PROTECTION STRUCTURE FOR DEEP  
SUB-MICRON GATE OXIDE §

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**AMENDMENT**

Dear Sir:

In response to the Office action of June 28, 2004, please amend the above-identified application as follows:

**Amendments to the Specification** begin on page 2 of this paper.

**Amendments to the Claims** are reflected in the listing of claims which begins on page 3 of this paper.

**Remarks/Arguments** begin on page 8 of this paper.

10/29/2004 SDIRETA1 00000022 10687314

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02 FC:1201 352.00 OP